Ref #	Hits	Search Query	DBs	Default Operator	Plurals	Time Stamp
L1	13	damascene and ((plasma adj etch$) same CO) and ((photoresist or resist) same (harden$ or resistance))	USPAT	ADJ	ON	2005/01/26 10:47
L2	13	damascene and ((plasma adj etch$) same CO) and ((photoresist or resist) same (harden$ or resistance))	US-PGPUB	ADJ	ON	2005/01/26 10:55
L3	0	damascene and ((plasma adj etch$) same CO) and ((photoresist or resist) same (harden$ or resistance))	EPO	ADJ	ON	2005/01/26 10:55
L4	0	damascene and ((plasma adj etch$) same CO) and ((photoresist or resist) same (harden$ or resistance))	JPO	ADJ	ON	2005/01/26 10:55
L5	0	damascene and ((plasma adj etch$) same CO) and ((photoresist or resist) same (harden$ or resistance))	IBM_TDB	ADJ	ON	2005/01/26 10:55
L6	0	damascene and ((plasma adj etch$) same CO) and ((photoresist or resist) same (harden$ or resistance))	DERWENT	ADJ	ON	2005/01/26 10:55